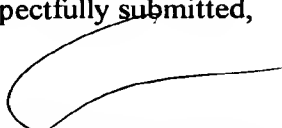


**REMARKS**

The Commissioner is hereby authorized to charge any fees associated with this response or credit any overpayment to Deposit Account No. 13-3402.

Respectfully submitted,



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Attorney Docket No.: KOJIM-436

Date: November 28, 2001

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**IN THE CLAIMS:**

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*Please amend the claims as follows:*

9. (Amended) A process for forming a resist pattern comprising the steps of:

applying the resist composition of claim 5 [or 6] onto a substrate to form a coating,

heat treating the coating and then exposing it to high-energy radiation having a wavelength of less than 300 nm or electron beams through a photo mask, and

optionally heat treating the exposed coating and developing it with a developer.